AMENDMENTS TO THE SPECIFICATION:

Please amend the specification as follows:

Please replace the paragraph on page 6, between lines 23-34, with the following:

At a point downstream of the valve V2, a stabilizer feed source 5 is connected to the line 12 via a line 13. The stabilizer feed source 5 [[is]] comprises a stabilizer reservoir 5a that reserves a stabilizer for an organometallic complex in a liquid state.

TMVS is used as the stabilizer when the organometallic complex is Cu (hfac) TMVS. _A valve V3', a mass flow controller 20 and a valve V3 are provided on the line 13,_in that order, from the stabilizer feed source 5 toward the line 12. _Depending on the kind of stabilizer to be used, in other words, if difficulty in vaporizing the stabilizer exists, a heater [[5a]] _5b may be provided at the stabilizer feed source 5 in order to promote vaporization of the stabilizer.

Please replace the paragraph on page 11, between lines 29-34, with the following:

According to the aforementioned embodiment, the stabilizer is fed into the gas area Av of the vaporizer 2. However, the stabilizer may be fed to a point downstream of the gas area Av of the vaporizer 2, for example, a suitable point of the line 14 between the vaporizer 2 and the reaction chamber 1 (for example, the point indicated by the arrow A in Fig. [[2]] 1).